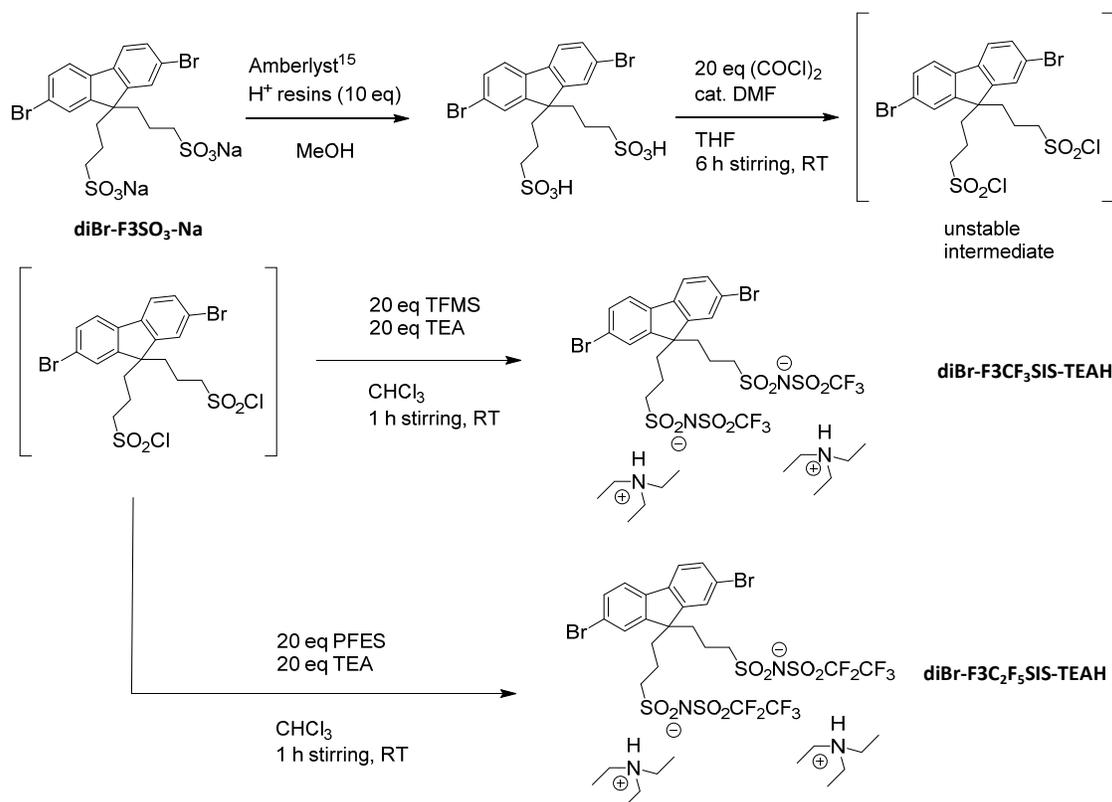


Supplementary Information S1

Materials. All reaction starting materials and reagents are either purchased from Sigma-Aldrich Pte Ltd or Tokyo Chemical Industry Ltd unless otherwise stated. diBr-F3SO₃-Na and diEs-mTFF starting monomers are synthesized according to reported procedures in Tang et al.¹ diEs-TFB starting monomer is obtained from Cambridge Display Technology Ltd/ Sumitomo Chemical Co.

Synthesis of 9,9-bis(3'-sulfonyl(trifluoromethanesulfonyl)imidopropyl)-2,7-dibromofluorene triethylammonium salt (diBr-F3CF₃SIS-TEAH) and 9,9-bis(3'-sulfonyl(pentafluoroethanesulfonyl)imidopropyl)-2,7-dibromofluorene triethylammonium salt (diBr-F3C₂F₅SIS-TEAH)



To a 100-mL Nalgene bottle, 3.5 g (5.7 mmol) of 9,9-bis(3'-sulfonatopropyl)-2,7-dibromofluorene sodium, diBr-F3SO₃-Na was dissolved in 70 mL of methanol (MeOH). 20 molar equivalents of Amberlyst 15 hydrogen form H⁺ resins (24.3 g, 114.3 mmol) were washed

to pH 7 with deionized water and added to the monomer solution. The solution was left on a mechanical roller for 6 h at RT. Upon completion, the solution was filtered through a 0.2- μm nylon syringe filter into a round-bottomed flask (rbf). The solution was concentrated yielding 9,9-bis(3'-sulfonatopropyl)-2,7-dibromofluorene acid form, diBr-F3SO₃H. Upon drying, diBr-F3SO₃H (2.47 g, 4.2 mmol) was added into a 150-mL 2-neck rbf, fitted with a stopcock valve adaptor. The rbf was pumped down to vacuum and backfilled with Ar thrice. 80 mL of distilled THF was added to dissolve the monomer. Catalytic dry DMF (0.25 mL) was added, followed by dropwise addition of oxalyl chloride (7.1 mL, 84.0 mmol). The reaction was left to stir at RT for 6 h. Chlorination yield can be monitored by ¹H NMR by quenching a small sample extracted from the reaction pot. Upon completion, the unstable 9,9-bis(3'-chlorosulfonylpropyl)-2,7-dibromofluorene intermediate, diBr-F3SO₂Cl was dried in-situ with vacuum and re-dissolved in anhydrous chloroform (40 mL).

In a 2nd rbf, trifluoromethanesulfonamide (TFMS, 12.5 g, 84.0 mmol) was mixed with anhydrous triethylamine (TEA, 11.7 mL, 84.0 mmol) in 30 mL of anhydrous chloroform. This mixture was transferred to the diBr-F3SO₂Cl solution and left to stir at RT for 1 h. Upon completion, the reaction was precipitated twice in diethyl ether, and redissolved in chloroform. After the 2nd redissolution in chloroform, the crude product was washed with water and precipitated in diethyl ether, yielding pure **diBr-F3CF₃SIS-TEAH** as white solid (4.2 g, Yield = 97%). ¹H NMR (400 MHz, DMSO-d₆), δ (ppm): 7.82-7.78 (d, 2H), 7.70 (s, 2H), 7.57-7.54 (d, 2H), 3.12-3.07 (q, 12H), 2.74-2.71 (t, 4H), 2.12-2.08 (t, 4H), 1.20-1.16 (t, 18H), 0.86-0.81 (m, 4H). ¹⁹F NMR (400 MHz, DMSO-d₆), δ (ppm): -78.8 (s)

To yield **diBr-F3C₂F₅SIS-TEAH**, in a 2nd rbf, replace TFMS reagent with pentafluoroethanesulfonamide (PFES) with all other reaction conditions and purification procedures remaining unchanged. Pure **2** is obtained as white solid (Yield = 95%). ¹H NMR (400 MHz, DMSO-d₆), δ (ppm): 7.82-7.78 (d, 2H), 7.70 (s, 2H), 7.57-7.54 (d, 2H), 3.12-3.07 (q, 12H), 2.74-2.71 (t, 4H), 2.12-2.08 (t, 4H), 1.20-1.16 (t, 18H), 0.86-0.81 (m, 4H). ¹⁹F NMR (400 MHz, DMSO-d₆), δ (ppm): -78.8 (s, 3F), -117.1 (s, 2F)

solids. ^1H NMR (400 MHz, DMSO- d_6), δ (ppm): 7.98 – 7.11 (m, 18H), 2.85 – 2.69 (m, 4H), 2.30 – 2.10 (m, 4H), 1.06 – 0.88 (m, 4H). M_n by ^1H NMR end-group analysis = 25 kDa.

To yield the **TFB-C₂F₅SIS-Na** polymer, replace **diEs-mTFF** with equimolar quantity of **diEs-TFB**, with all other reaction conditions and purification procedures remaining unchanged. Pure **TFB-C₂F₅SIS-Na** is obtained as off-white solids as well. ^1H NMR (400 MHz, DMSO- d_6), δ (ppm): 7.87 – 7.07 (m, 18H), 2.76 – 2.56 (m, 5H), 2.25 – 2.18 (m, 4H), 1.61 – 1.57 (m, 2H), 1.25 – 1.23 (m, 3H), 0.99 – 0.82 (m, 7H). M_n by ^1H NMR end-group analysis = 23 kDa.

Ion-exchange of Na cation in TFB-X-Na and mTFF-X-Na polymers

In a 100-mL Nalgene bottle, Amberlyst hydrogen form H^+ resins (1.7 molar equvi/mL by wetted bed volume, Sigma-Aldrich Pte Ltd) were conditioned to the tetramethylammonium ($^+\text{NMe}_4$) and tetraphenylphosphonium ($^+\text{PPh}_4$) cations by addition of 1.5 molar equivalents of their respective tetramethylammonium hydroxide and tetraphenylphosphonium bromide in aqueous solvent and left on a mechanical roller at room temperature for 3 h. The ion-exchanged resins were then rinse-washed with deionized water until pH 7, and pre-conditioned in acetonitrile for 24 h. TFB-CF₃SIS-Na was dissolved in acetonitrile at 50 mg/mL and added to 20 molar equivalents of ion-exchange resins. The mixture was left on a mechanical roller at room temperature for 6 h. The solutions were concentrated and precipitated in diethyl ether. The TFB-CF₃SIS-NMe₄ and TFB-CF₃SIS-PPh₄ polymers are further purified by dialysis in acetonitrile through a regenerated cellulose membrane (MWCO = 12-14 kDa) for 1 h for four times. The dialysed polymers were retrieved by precipitation in diethyl ether and dried under vacuum.

Solvent for undoped TAF polymers

X =	M =	Solubility (>20 mg ml ⁻¹)						
		DMSO	MeOH	ACN	PC	Acetone	NM	TFE
SO ₃	Na	Y	Y	N	N	N	Y	Y
	NMe ₄	Y	Y	N	N	N	Y	Y
	PPh ₄	Y	Y	Y	Y	Y	Y	Y
C ₃ FSIS	Na	Y	Y	Y	Y	Y	Y	Y
	NMe ₄	Y	Y	Y	Y	Y	Y	Y
C ₂ F ₅ SIS	Na	Y	Y	Y	Y	Y	Y	Y

Table 1. Solubility characteristics of TFB-X-M and mTFF-X-M, where M is the cation. Both the TFB and mTFF cores exhibit the same behavior, and are thus not repeated in the table for brevity. M = Na, NMe₄ or PPh₄, where NMe₄ is tetramethylammonium, and PPh₄ is tetraphenylphosphonium. Solubility: Y = Yes, N = No. Solvents: DMSO, dimethyl sulfoxide; ACN, acetonitrile; PC, propylene carbonate; MeOH, methanol; TFE, 2,2,2-trifluoroethanol; NM, nitromethane.

Atomic force microscopy of undoped and SC hole-doped TAF polymers

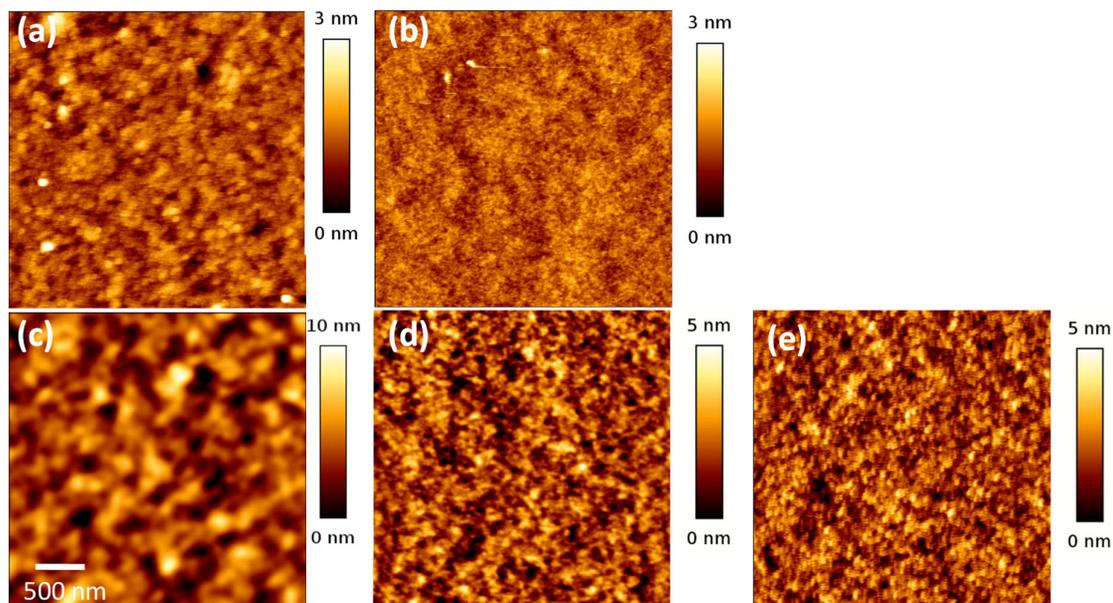


Figure 1. $3 \times 3\text{-}\mu\text{m}$ atomic force microscopy images of pristine and SC hole-doped polymers. 90-nm-thick undoped **(a)** TFB-CF₃SIS-Na, **(b)** TFB-C₂F₅SIS-Na. 30-nm-thick SC hole-doped **(c)** TFB-CF₃SIS-Na and **(d)** TFB-C₂F₅SIS-Na **(e)** mTFF-C₂F₅SIS-Na films. Undoped films are spin-cast from 20 mM polymer solutions in ACN while SC hole-doped films are spin-cast from 15 mM hole-doped solutions in ACN and filtered through 0.45- μm nylon syringe filter onto O₂-plasma cleaned glass substrates. RMS roughness of **(a)** – **(e)** films are 0.34 nm, 0.25 nm, 1.50 nm, 0.77 nm and 0.71 nm respectively. Tapping-mode AFM.

Reference

1. C.G. Tang, M.C.Y. Ang, K.K. Choo, V. Keerthi, J.K. Tan, M. Nur Syafiqah, T. Kugler, J.H. Burroughes, R.Q. Png, L.L. Chua, and P.K.H. Ho, *Nature*, 2016, **539**, 536.